

Supporting Information

A highly sensitive redox-active monolayer for “signal-on” optical detection of iron(II)

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Materials and Methods: Most of the metal salts were purchased from BDH Chemicals Ltd and used as received. $\text{RuCl}_3 \cdot 3\text{H}_2\text{O}$, 3-iodo-n-propyl-trimethoxysilane, 2,2'-bipyridine, 4,4'-dimethyl, 2,2'-bipyridine and ammonium hexafluorophosphate were purchased from Aldrich and used as received. $\text{Ce}(\text{SO}_4)_2 \cdot 4\text{H}_2\text{O}$ was purchased from BDH Chemicals Ltd and used as received. Anhydrous FeCl_3 and FeCl_2 were purchased from Merck and Aldrich respectively. Methanol and ethanol were purchased from Merck and was distilled over activated magnesium turnings and iodine before use. 30% aq. Ammonia, H_2O_2 , dry n-pentane, toluene, dichloromethane and acetonitrile (All AR grade) were purchased from s. d. fine chemicals (India). Dichloromethane (DCM) was purified with H_2SO_4 and distilled under N_2 over P_2O_5 , degassed and was stored over activated 4 Å molecular sieves in brown bottle. Deuterated solvents were purchased from Aldrich. Glass slides having thickness $\sim 1.0\text{--}1.2$ mm were purchased from Pearl India and single-crystal silicon [100] substrates were purchased from Beschichtungen (Silz, Germany). Indium tin oxide coated glass was purchased from Environ sales (India). Hydrothermal bombs (25mL & 50mL) were purchased from Prakash Scientific Works (India). Water used for the experiment was double distilled.

Si(100) and ITO coated glass were cleaned by sonication in hexane followed by acetone, then ethanol and dried under an N_2 stream. Soda-lime glass was cleaned by immersion in a "piranha" solution (7:3 v/v, H_2SO_4 /30% H_2O_2) for 1 h. (*Caution: Piranha is an extremely dangerous oxidising agent and all protective measures must be adopted to prevent any harm*). Subsequently, this was rinsed with deionized water followed by RCA cleaning protocol: 1:5:1 (v/v) $\text{NH}_3 \cdot \text{H}_2\text{O}$ / H_2O /30% H_2O_2 at room temperature for 45 min. The substrates were washed with ample amount of deionized water and were dried under an N_2 stream. All substrates were dried in an oven for 2 h at 130°C . The monolayer formation was carried out under an inert atmosphere using standard Schlenk/cannula techniques. 4'-Methyl-4-(2-pyridin-4-yl-vinyl)-[2,2']bipyridinyl and $\text{Ru}(\text{bipyridine})_2\text{Cl}_2 \cdot 2\text{H}_2\text{O}$ were prepared according to published procedures^{S1,S2} and characterized by ^1H NMR.

UV-Vis spectroscopy was carried out using a JASCO UV-Vis-NIR spectrophotometer (670D). Elemental analyses were performed on a GmbH VarioEL elemental analyzer. Mass spectra were recorded on THERMO Finnigan LCQ Advantage max ion trap mass spectrometer (MSAIF, CDRI, Lucknow, India). Atomic force microscopy (AFM) images were recorded using a Solver P47 (NTMDT) operated in the tapping mode. OTESP-type Si SPM probes were used with a resonance

frequency of tip ~ 250 kHz and a tip radius of ~ 10 nm. Roughness data were extracted from $1000\text{ nm} \times 1000\text{ nm}$ images. CHI-660D electrochemical analyzer was used to carry out electrochemical measurements. pH meter was calibrated before each measurements using standard buffer solution of pH 4 and pH 10. All ^1H NMR spectra were recorded on Jeol JNMECX 400P spectrometer. All chemical shifts (δ) are reported in ppm, and coupling constants (J) are in Hz. The ^1H NMR chemical shifts are relative to tetramethylsilane; the resonances of the residual protons of the solvent were used as an internal standard for ^1H . All measurements were carried out at 298 K, unless otherwise stated.

Preparation of Precursor Complex: The precursor complex of **1** were synthesized by the method as reported earlier^{S3,S4}. The reaction of $\text{Ru}(\text{bipyridine})_2\text{Cl}_2 \cdot 2\text{H}_2\text{O}$ (200 mg; 0.385 mmol) with 4'-methyl-4-(2-pyridin-4-yl-vinyl)-[2,2']bipyridinyl (126 mg; 0.46 mmol) under reflux in 50 mL ethanol-water (1:1, v/v) for 7h gives dark brown color solution this was concentrated to 10 mL under vacuum. The desired complex was precipitated by adding saturated aqueous solution of ammonium hexafluorophosphate [163 mg (1.0 mmol) in 3 mL] and filtered off. This was washed with an excess of water, then ether and purified by column chromatography using alumina (neutral, activity G-III) column and toluene-acetonitrile (80:20 v/v) as eluent. The first dark brown fraction was collected and dried under *vacuo*. Yield: 233 mg (62%). Anal. Found (%): C, 46.86; H, 3.19, Calc. (%) for $\text{RuC}_{38}\text{H}_{31}\text{F}_{12}\text{N}_7\text{P}_2$: C, 46.73; H, 3.20. ^1H NMR (CD_3CN): δ 8.58 (3H, m), 8.50 (5H, d), 7.77 (4H, m), 7.71-6.87 (14H, m), 7.64 (1H, d; $J = 16.4$ Hz), 7.53 (1H, d, $J = 16.4$ Hz), 2.56 (3H, s). ES MS: m/z : 343.64 ($\text{M}^{2+} - 2\text{PF}_6$). UV-vis (CH_3CN), λ , nm (ϵ , $\text{M}^{-1}\text{cm}^{-1}$): 456 (17831), 329 (18145), 285 (66397), 242 (25940).

Preparation of Complex 1: An excess of 3-iodo-n-propyl-1-trimethoxysilane (81 mg, 0.28 mmol) was added to a dry THF/acetonitrile (90:10 v/v) solution (20 mL) of precursor complex (55 mg, 0.056 mmol) under N_2 in a pressure vessel. The reaction mixture was stirred and heated at 90°C for 48h. Subsequently, the volume was reduced to ~ 2 mL. The addition of dry pentane (15 mL) at 25°C to reaction mixture resulted in the precipitation of the desired product. The solvent was decanted and the precipitate was washed with dry pentane up to 3 times then dried under vacuum to get the desired product (complex **1**). Yield: 60 mg (85%). Anal. Found (%): C, 41.83; H, 3.69, Calc. (%) for $\text{RuC}_{44}\text{H}_{46}\text{F}_{12}\text{IN}_7\text{O}_3\text{P}_2\text{Si}$: C, 41.71; H, 3.66. ^1H NMR

(400 MHz, CD₃CN): δ 8.79–7.15 (26H, m; ArH and 2H, d; -CH=CH-), 4.45 (2H, t; -CH₂-), 3.53 (9H, s; -OCH₃), 2.59 (3H, s; -CH₃), 0.89 (2H, m; -CH₂-), 0.65 (2H, t; -CH₂-). UV/vis (CH₃CN), λ , nm (ϵ , M⁻¹cm⁻¹): 459 (21326), 335 (24731), 282 (90740), 239 (36439).

Scheme S1. Schematic representation for the preparation of complex **1**.

Formation of Monolayer: Under N₂, freshly cleaned quartz, glass, ITO and silicon substrates were loaded into a hydrothermal bomb equipped with home-made Teflon holder and immersed in dry acetonitrile/toluene (3:7 v/v) solutions (0.5 mM) of complex **1** and heated for 52h at 80 °C with the exclusion of light. The functionalized substrates were then rinsed with dichloromethane, acetonitrile and sonicated gently for 5 min each in acetonitrile and isopropanol. The samples were then wiped with a task wipe then dried under a stream of N₂. Finally, the samples were cleaned with CO₂ snow jet cleaning system and stored in the dark.

Reversibility tests: alternating treatment of the sensors with Fe(II) and Ce(IV) in air. The double-side coated **1**-based monolayers on glass were chemically activated with [Ce(SO₄)₂·4H₂O] (1.0 mM, in water containing 0.01 M H₂SO₄, 3 min) in air to yield the ruthenium(III) chromophore-based monolayer. The oxidized monolayer was fully reduced with FeCl₂ to yield Ru(II)-based monolayer. Several oxidation/reduction cycles were obtained by immersion of the functionalized glass substrates for 3 min in a 0.01 M solution of H₂SO₄ (10 mL) containing 1.0 mM [Ce(SO₄)₂·4H₂O], and 2 min in a FeCl₂ (1.0 ppm in CH₂Cl₂) solution (10 mL), respectively. The substrates were rinsed with dry CH₃CN, gently cleaned with task paper and dried at room temperature under a gentle stream of N₂ before recording the absorption spectrum. The experiment was repeated for eight Ru(II)/Ru(III) cycles (Figure 2).

Preparation of CH₂Cl₂ samples with ppb/subppm-levels of FeCl₂. A stock solution of 400 ppm of FeCl₂ in dry MeCN was made by dissolving 8 mg FeCl₂ in 20 mL dry MeCN, which was further diluted several times with CH₂Cl₂ to generate solutions containing 1, 0.5, 0.3, 0.2, 0.1, 0.05, 0.02, 0.01 and 0.005 ppm of FeCl₂ respectively. The sample preparation was carried out using silanized glassware.

Sensing of subppm-levels of FeCl₂ in CH₂Cl₂. Precautions were taken to exclude the presence of water throughout the experiment. The activated ruthenium(III)-based monolayers on glass substrates were tested in series of CH₂Cl₂ samples containing 1, 0.5, 0.3, 0.2, 0.1, 0.05, 0.02, 0.01 and 0.005 ppm of FeCl₂, respectively. In a particular set of experiments, the substrates were immersed in a CH₂Cl₂ solution containing 0.1 ppm of FeCl₂ for 2 min, rinsed with dry CH₂Cl₂ and carefully wiped with task paper before recording the UV-Vis spectra. Subsequently the monolayer was activated with [Ce(SO₄)₂·4H₂O] (1.0 mM, in water containing 0.01 M H₂SO₄, 3 min), wiped with task paper and fully dry under N₂ flow. The full recovery of the system was confirmed by UV-Vis analyses. This procedure was repeated using same monolayers and CH₂Cl₂ samples containing 1, 0.5, 0.3, 0.2, 0.05, 0.02, 0.01 and 0.005 ppm of FeCl₂, respectively (Figure 3). In another set of experiment, the reduction of the **1**-based monolayers on glass (1 cm × 2.5 cm) with 0.01 ppm FeCl₂ was followed as a function of time and monitored *ex-situ* with UV/Vis spectrophotometer (Figures 3, inset).

Selectivity test in organic and aqueous matrix. The solutions of the metal salts (NaCl, KCl, CaCl₂, MgCl₂, NiCl₂, ZnCl₂, CuCl₂, FeCl₃, RhCl₃, FeCl₂) and solvents (C₆H₆, CH₃CN, H₂O) used for selectivity study were made by dissolving the corresponding salt in dry CH₂Cl₂, CH₂Cl₂/DMF (3:1 v/v) or deionized H₂O (1 × 10⁻⁴ M each). The pH (≈1) of the aqueous solutions of metal salts was adjusted using 32 % HCl. The **1**-based monolayer was immersed in the above solutions for 3 min each followed by washing in dry CH₂Cl₂ and drying under N₂ stream before recording UV-Vis spectra.

Stability test of the 1-based monolayer. **1**-based monolayer was subjected to thermal stress. The samples were placed inside a sealed glass pressure tube under air. The thermal stability was monitored by *ex-situ* UV-Vis measurements at 200 ± 5 °C for varying time intervals (1, 3, 6, 10, 22, 29 and 49 h). The temporal stability

was monitored by keeping the samples for >1h at various temperatures (i.e., 25, 80, 100, 120, 180, 200, and 230 °C). Before each temperature increase, the samples were allowed to attain room temperature, rinsed with CH₃CN, gently wiped with task paper and analyzed by UV-Vis spectrophotometry (Figure 5). After thermal stress experiment the sample was tested for sensing/resetting experiments for four cycles (Figure 5, inset).

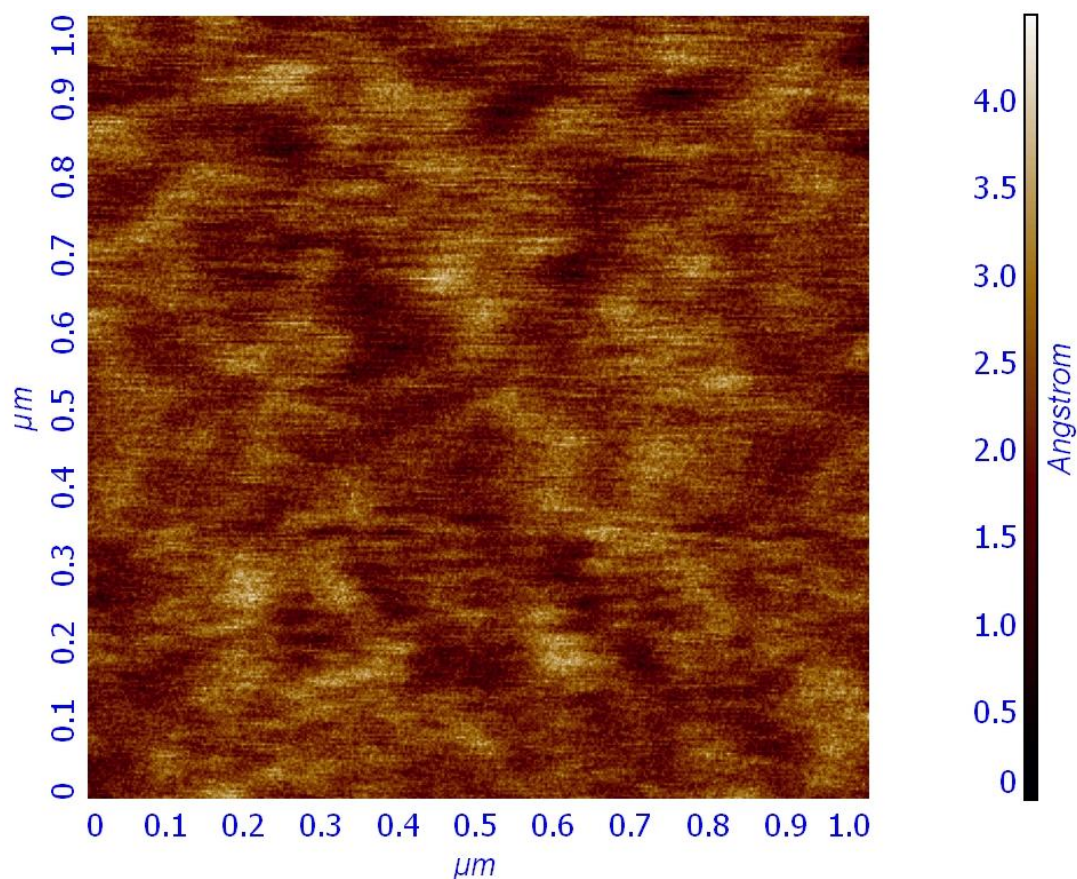


Figure S1. AFM image of **1**-based monolayer on Si(100) operated in tapping mode using a Si OTESP-type SPM probe with a resonance frequency of 346.4 kHz. Scan speed 1.6 Hz. No pinholes or other defects were observed, though there is some evidence of interaction between the films and the tip. Root-mean-square surface roughness (Rq) on Si = 0.097 nm for 1000 × 1000 nm scan area.

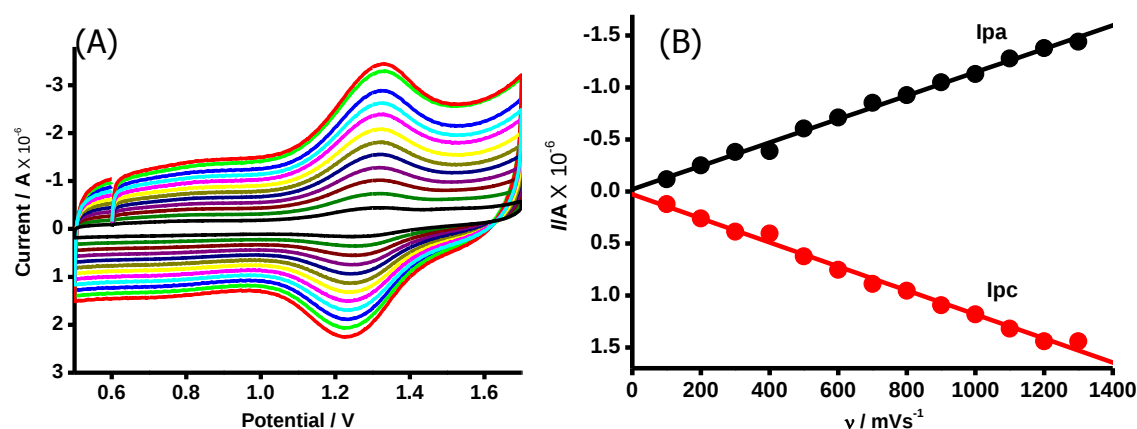


Figure S2. (A) Representative cyclic voltammetric responses at different scan rates of the **1**-based monolayer on ITO-coated glass, which operates as the working electrode. Pt wires were used as reference and counter electrodes. The electrochemical (EC) experiments were carried out at room temperature in dry CH_3CN containing tBu_4NPF_6 (20 mM) with a CHI660D potentiostat. The voltage scan rate was varied from 100 to 1300 mVs^{-1} . $E_{1/2} = 1.27 \text{ V vs Pt}$; 0.90 vs Fc/Fc^+ , $\Delta E = 50 \text{ mV}$. Footprint calculated using area under the peak was $80 - 100 \text{ \AA}^2/\text{molecule}$. (B) Linear correlation of the peak current I_{pa} and I_{pc} versus the scan rate ν for scan rates starting from 100 mV/s to 1300 mV/s , ($R^2 \approx 0.99$).

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